

Search Notes

Application No.

09/771,640

Examiner

Toan Ton

Applicant(s)

PARK, KU-HYUN

Art Unit

2871

SEARCHED

| Class | Subclass | Date | Examiner |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
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